
Practice for dosimetry in an electron beam facility for radiation processing at energies between 80 and 300 keV

*Pratique de la dosimétrie dans une installation de traitement par
irradiation utilisant un faisceau d'électrons d'énergies comprises
entre 80 et 300 keV*

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ISO copyright office
CP 401 • Ch. de Blandonnet 8
CH-1214 Vernier, Geneva
Phone: +41 22 749 01 11

Email: copyright@iso.org
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ASTM International
100 Barr Harbor Drive, PO Box C700
West Conshohocken, PA 19428-2959, USA
Phone: +610 832 9634
Fax: +610 832 9635
Email: khooper@astm.org
Website: www.astm.org

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